# Combinatorial approaches for hydrogen storage materials

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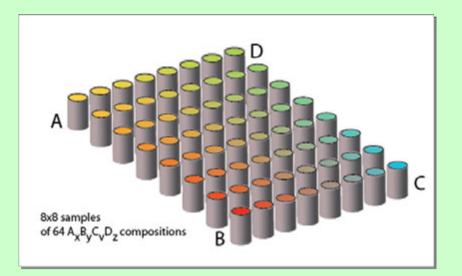
Contributors: G. Downing, E. Mackey, R. Paul, R. Greenberg (NIST:CSTL); L. Cook, M. Green (NIST:MSEL) R. Cavicchi (NIST:CSTL); I. Takeuchi, H. Oguchi (UMd)

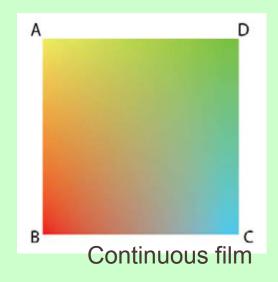
# Two Main Challenges to Combinatorial Analysis of Hydrogen Storage Materials

- Design and fabrication of appropriate materials libraries
- Rapid, quantitative measurements of hydrogenation phenomenon

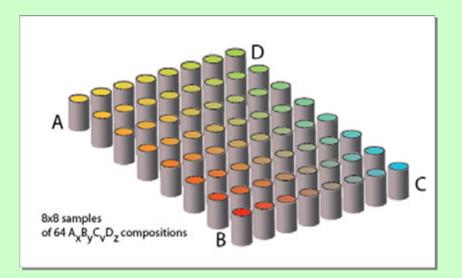
We are attacking both of these problems at NIST

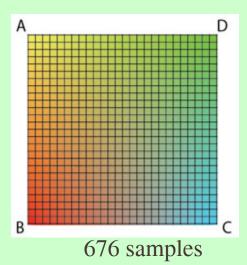
### **Combinatorial Library Fabrication**





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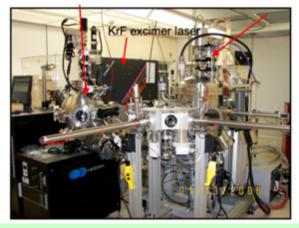


Density of samples are determined by the spatial resolution and sensitivity of a measuring probe



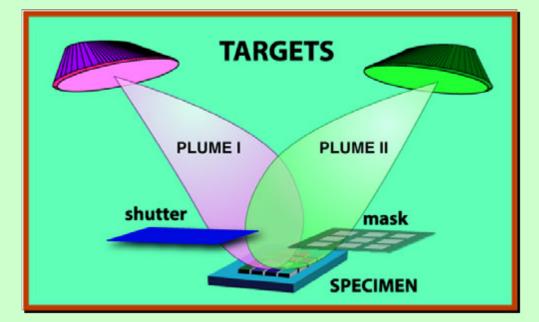
# E-beam system with automated moving shutter/mask control

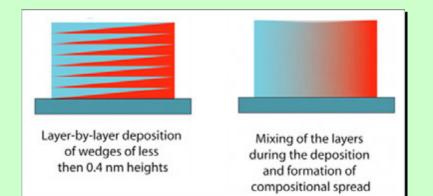
Natural-Spread Combinatorial PLD System Shutter-based Combinatorial sputtering System



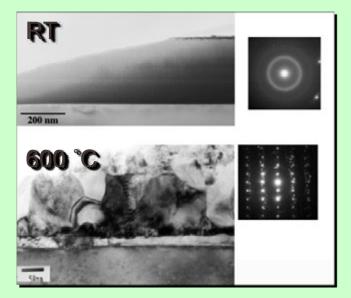
**Dual PLD/Sputtering** 

## **Combinatorial Library Fabrication**





#### 



# **NIST Success in Combinatorial Methods**

Studied systems	Properties	Synthesis	HTP Tools
* BaTiO <sub>3</sub> - SrTiO <sub>3</sub>	High dielectric material	PLD, Precursors,	Scanning microwave
	for microwave	multilayers	microscope
* ZnO-MgO	band gap of ZnO	PLD	Optical transmission
	semiconductor	multilayers	
* LaMnO <sub>3</sub> - CaMnO <sub>3</sub>	CMR material, magnetic	PLD	Magneto-optical
	diagrams	multilayers	imaging
* BaTiO <sub>3</sub> -CoFeO <sub>4</sub>	Multiferroic material	PLD	Scanning SQUID
		multilayers	Scanning microwave
			microscope
Metals on GaN	Electric contacts	e-beam	Electrical measurements
* $Fe_{(1-x)}Ga_x$ (x=0-0.4)	Magnetostriction	Sputtering	Micromachined
		Co-deposition	cantilevers
Fe <sub>2</sub> Ti-FeTi-Ti <sub>2</sub> Fe	Hydrogenation	e-beam	IR imaging
		multilayers	
Mg-Mg <sub>2</sub> Ni-MgNi	Hydrogenation	e-beam	IR imaging
		multilayers	
LaNi5, FeTi, Pd	Hydrogenation	PLD, Sputtering	Nanocalorimetry
TaN - AIN	Advanced gate stack for	Reactive Sputtering	Automated C-V analysis
	Si CMOS		
$(Ca_{1-x-y}Sr_xLa_y)_3Co_4O_9$	Thermoelectric	PLD	Automated Seebeck
	(Seebeck coefficient)		coefficient
			measurements

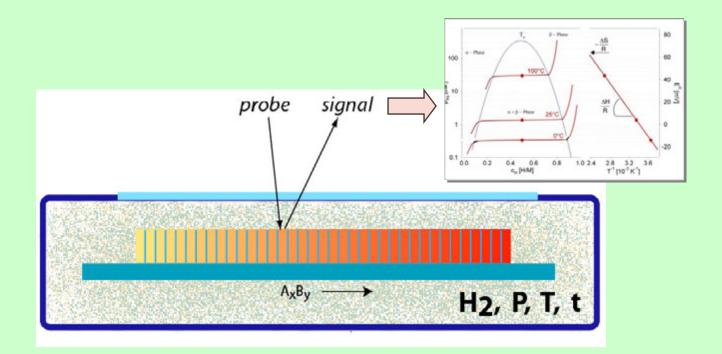
\* - in collaboration with Prof. I. Takeuchi, UMD

# High-throughput metrology for

### combinatorial analysis of hydrogenation

### **Ultimate Goal**

To measure the hydrogenation process in a library element  $(A_XB_Y)$ (amount of H in the material at given P, T and time)



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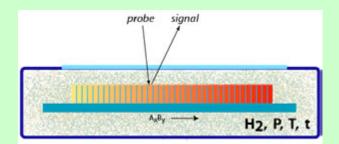
### Indirect measurements of H concentration:

Changes in physical properties due to hydrogenation; in-situ; correlation between the amount of hydrogen and the physical property:

- Optical transmission (metal-to-insulator) *Prof. Griessen group*;
- Cantilever bending (stress changes) Ludwig;
- IR emissivity GM, GE, NIST;
- Micro-Raman NIST;
- MOKE (NIST-Boulder);

### Limitations:

- Not universal (material-dependent)
- Difficult to estimate the amount of hydrogen

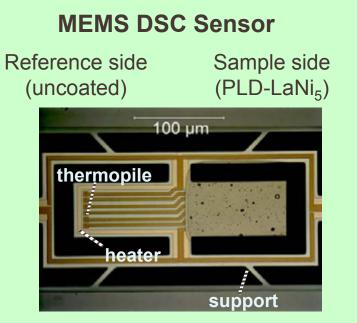


# **Thin-Film Nanocalorimetry of Hydrogen Absorption**

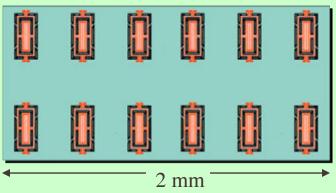
- Calorimetric signatures:
   △H (absorption) -> exothermic
   △H (desorption) -> endothermic
- Sensors will measure:

   enthalpy,
   activation energy
   of hydrogenation in thin-films
- Sensor size is suitable for combinatorial arrays

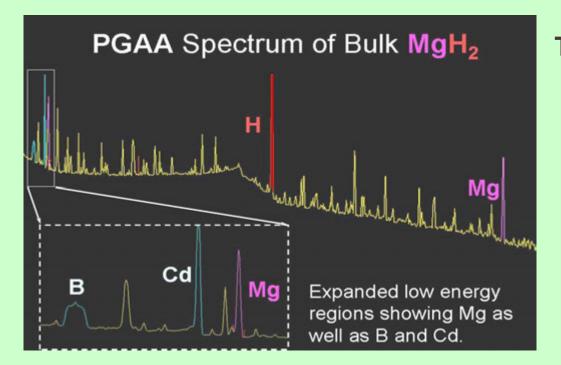
L. Cook, M. Green (MSEL, NIST) R. Cavicchi (CSTL, NIST)



### **Propose Array of DSC Sensors**



# **DIRECT** Measure of Hydrogen Content Prompt Gamma Activation Analysis



### **Technique Features:**

- Quantitative
- Multi-element Analysis (H)
- Non-destructive
- Easy Sample Preparation

### PGAA: non-destructive, multi-elemental analysis technique

- Neutron Beam irradiation of sample  $\rightarrow \gamma$ -ray emission
- γ-ray spectra give elemental composition and concentration (even hydrogen!)
- Quantitative when calibrated with elemental standards

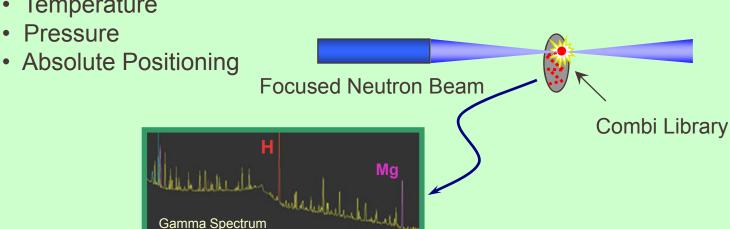
Chemical Science and Technology Laboratory (NIST: CSTL)

# Making the PGAA Combi

# **Three Analytical Challenges**

#### Analysis of thin film specimens

- Target: Library Arrays  $0.3 \ \mu m$  to  $4 \ \mu m$  thick films
- Elemental: phase diagrams
- Environmental Control
  - Temperature
  - Pressure



- Spatial Mapping
  - Neutron Optics
  - Gain in Quantitation
  - Gain in Resolution

# **Summary**

# **NIST Library Fabrication**

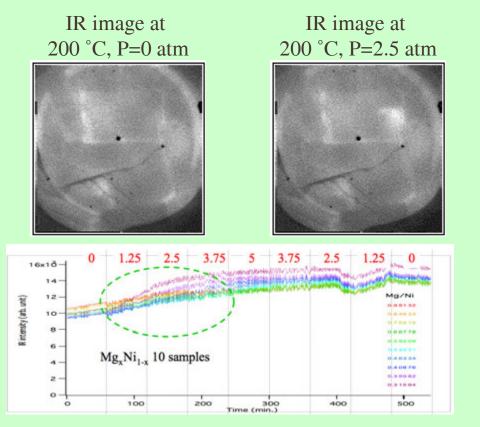
- Library deposition facilities suitable for metallic specimens in place
- New chambers will work with Li, Ca,  $B \rightarrow$  borates, amides...

# **NIST Measurements**

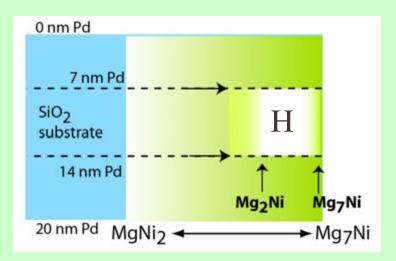
- In-situ Combi Prompt Gamma Activation Analysis (PGAA)
  - Quantitative H concentration measurements
  - Simple for interpretation, equivalent to the standard PCT measurements.
  - Leverages upgrade of NIST Center for Neutron Research
  - Lots of potential, challenges for combi
- Nanocalorimetry arrays
  - Rapid screening of hydrogen absorption
  - Parallel tracking of storage material kinetics

# Infrared emission characterization of hydrogenation

### Example of hydrogenation of the Mg7Ni-MgNi2 compositional spread



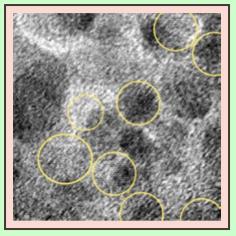
Evolution of IR intensity with time for different compositions of the film (200  $^{\circ}$ C at different pressures of H<sub>2</sub>).



Schematic drawing showing that the maximum increase in IR intensity occurred for the compositions ranging between  $Mg_2Ni$  and  $Mg_7Ni$ , and Pd coating thicker then 7 nm. According to TEM, thinner Pd coating doesn't cover Mg-Ni film and therefore oxidation prevents hydrogenation of the film.

### **NIST Hydrogen Storage Initiative - M<sup>3</sup> of MSEL Tasks**

# Materials



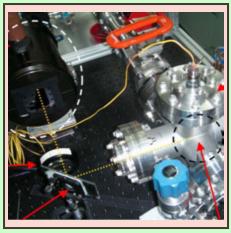
# Combinatorial thin films of light-weight alloys

Metal-doped carbonbased thick porous films

Light-weight TCP intermetallic compound and quasicrystals

Mg bulk and rapidly solidified alloys

# Measurements



# High-throughput metrology for combinatorial search

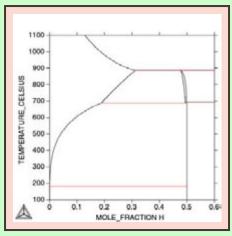
- In-situ IR emissivity
- In-situ micro-Raman
- In-situ PGAA of films
- In-situ MOKE of films

# TEM of hydrogenated materials

#### Nanocalorimetry

In-situ synchrotron studies, SANS, x-ray

### Modeling



#### CALPHAD

#### Thermodynamic modeling

Thermodynamic database to support experiments

#### HIGH THROUGHPUT/COMBINATORIAL SCREENING OF HYDROGEN STORAGE MATERIALS

#### **OBJECTIVES**

- Assess the potential for High Throughput Screening/Combinatorial methods to benefit and accelerate Hydrogen Storage Materials R&D
- Identify the advantages and disadvantages of the application of High Throughput/Combinatorial techniques to Hydrogen Storage Materials R&D
- Match High Throughput Screening/Combinatorial techniques with specific types of Hydrogen Storage Materials
- Identify the technical challenges and limitations associated with applying these techniques to Hydrogen Storage Materials R&D
- Recommend appropriate NNext Steps, Óif any, to advance the application of these techniques to hydrogen storage materials

#### PRELIMINARY AGENDA

9:00am Welcome/Introductions/Objectives - Ned

9:10am Status of Hydrogen Storage Materials R&D - Sunita

- 9:30am Summaries of Present High Throughput Screening/Combinatorial Activities (20 minutes each)
  - Internatix
  - UOP
  - GE Research

1030am Break (15 minutes)

- NIST
- UCF/DoD
- Symyx Technologies
- Others from the Audience (30 minutes)

#### 12:00pm Lunch

1:00pm Breakout Group Discussions Š Led by Carole, Grace, Ned (3groups-metal hydrides, adsorbents, chemical hydrogen storage)

- Benefits of Hi ThruPut Screening/Combinatorial Techniques
- Challenges/Disadvantages
- Matching of Techniques w/ specific storage materials

2:30pm Break

- 2:45pm Breakout Group Summaries Š Sunita or Ned
  - Action Items
  - **Open Discussion**
  - Next Steps
- 4:00pm Adjourn